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CAPITAL MARKETS DAY 2020 INSIGHTS EXPOSURE

September 24th, 2020

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SUSS EXPOSURE TECHNOLOGIES



Proximity Exposure

Lithographic Wafer & Substrate Structuring

Micro-bumping, Flip Chip, Wafer-Level-Packaging

MEMS, RF, Power Devices, Photonics, LED

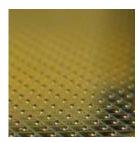
Nano- and Micro-Imprinting

Nano- & Micro-Structuring

WLO, Photonics, ID recognition, AR (DOE, optical gratings), medical, surface patterning



Highest resolution patterning

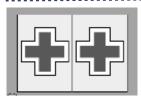


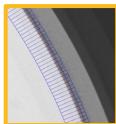
on glass substrate

Metrology

Image Processing

Smart Manufacturing Solutions





Direct Write Projection

Individual Die Processing Highly flexible patterning

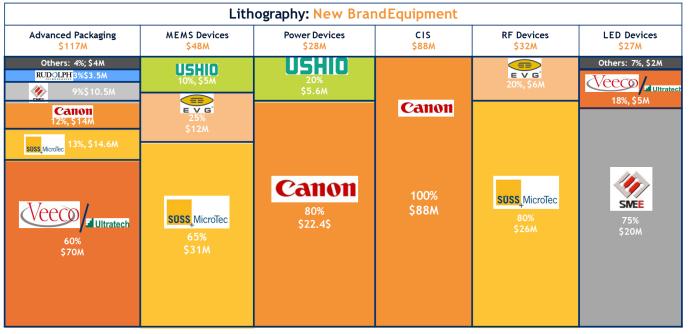


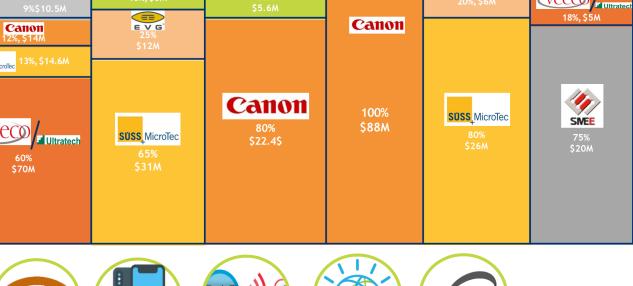


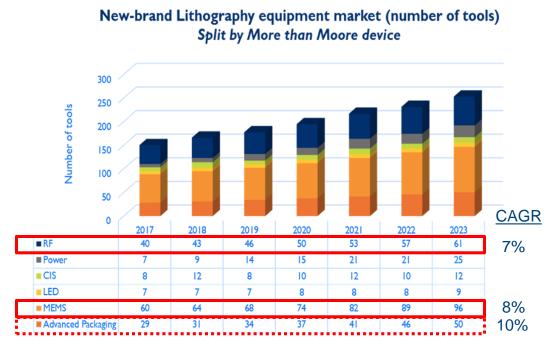
MORE THAN MOORE MARKET AND TECHNOLOGY TRENDS - APPLICATION DRIVERS FOR SUSS EXPOSURE TECHNOLOGIES



- Demand for "More than Moore" equipment is expected at CAGR of 7%-10% by Yole Développement
- SUSS Exposure solutions have a dominant share for MEMS and RF devices
- Target to expand share in Advanced Packaging with Direct Write Projection

















RF

MEMS

Source: Yole (2018, 2019)

TARGET APPLICATIONS FOR MICRO-IMPRINT

SUSS MicroTec

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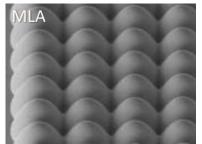


UV - stacking











Light carpets

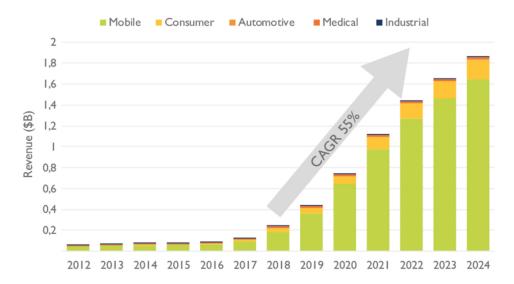
Camera modules

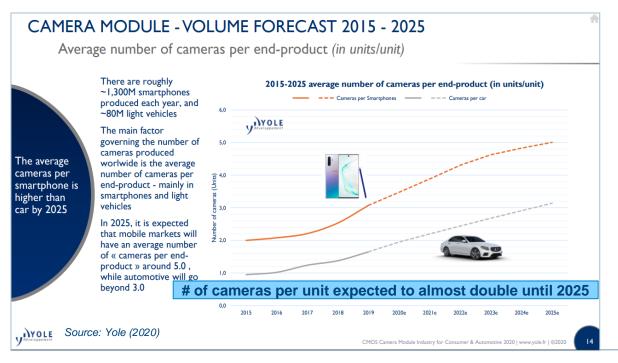
Fingerprint sensors

Face ID optics
Time of Flight sensors

2012-2024 Wafer Level Optics revenue forecast by application (in \$B)

(Source: Status of the Camera Module Industry 2019 - Focus on wafer level optics , Yole Développement, February 2019)

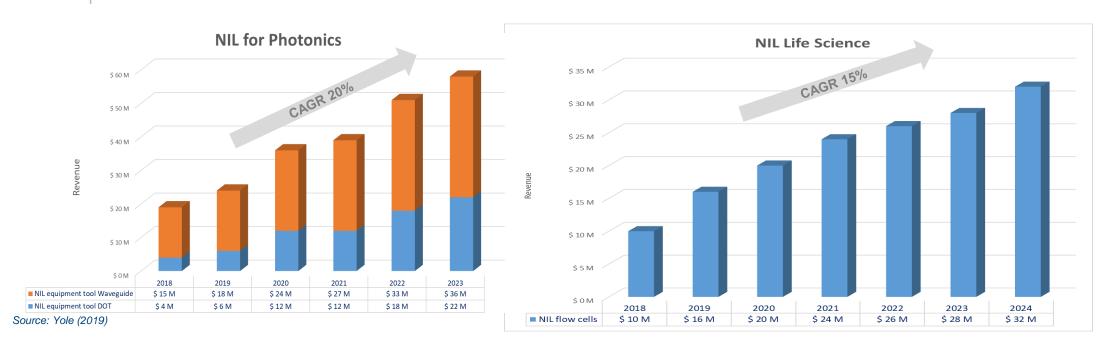




TARGET APPLICATIONS FOR NANO-IMPRINT

SÜSS_MicroTec

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Nano - Imprint



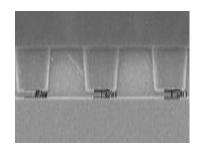
TelecommunicationOptical nano-gratings



Virtual reality visors
Optical gratings



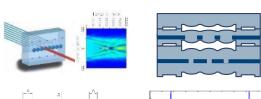
Augmented Reality
Diffractive optical elements

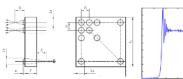


Life scienceDNA sequencing, organ-on-chip

IMPRINT EXCELLENCE CENTER FULL SERVICE @ SUSS MICROOPTICS SITE

SUSS MicroTec





Optical Design, System Design, **Micro-Optics Simulation**











Fully equipped metrology lab for inspection and sorting of micro-optical components. (ISO 9001, IATF 16949, Six Sigma)

















Full access to peripheral tooling (Master and stamp fabrication, etching, dicing)







From feasibility studies for micro- and nanoimprint up to small volume production Full production environment using the expertise of SUSS MicroOptics volume fabrication Start-Up service for SUSS customers

SUSS METROLOGY: ENABLER FOR PRODUCTION TOOLS



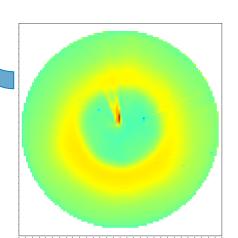
Feedback Loop

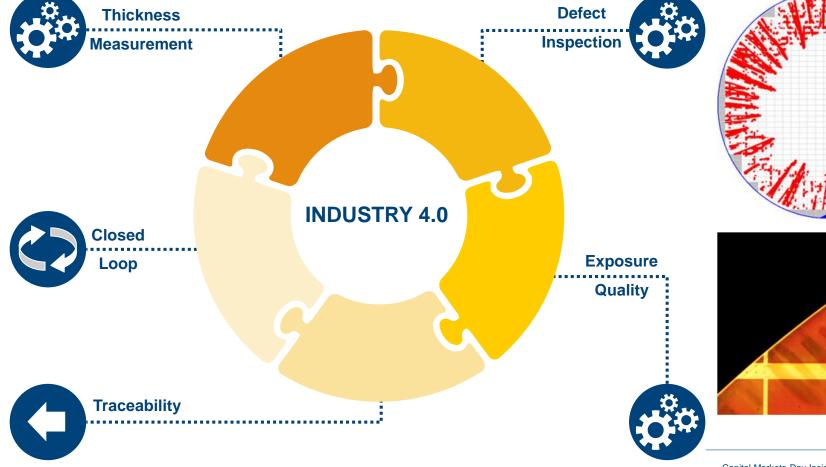
Enhance product portfolio with Smart Manufacturing Solutions – Secure the High Wafer Value



Automation:

- **Adjust Recipe**
- Repeat process
- **Alert host**





PRODUCT PORTFOLIO

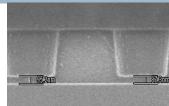


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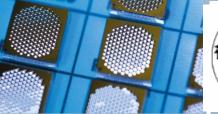
SUSS Exposure Systems



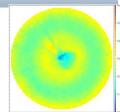












Semi-Automated Aligners

Automated Aligners

Imprint

Metrology







MA12



MA150



MA200



MA300



XLC200 (coming soon)



DSM200



DI200

Comment / USP

Large install base, very versatile

Only offer in the market. Used for special Morethan-Moore Very high throughput, Linear transport, For cost-sensitive applications Flagship product.
Large install base,
very versatile
Overlay < 1um

ict. O ise, U e P

Only offer in market.
Used for Advanced
Packaging with less
challenging
requirements

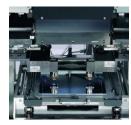
Development targeted for HVM applications in both markets, micro-imprint and nano-imprint. Strong process focus together with SMO DSM is dedicated offering for back-side alignment processes. Modules integrated in SUSS systems for smart manufacturing control

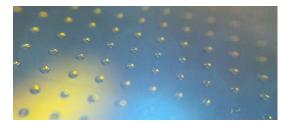
SUMMARY GROWTH POTENTIAL – ON TRACK WITH SUSS STRATEGY 2025 PROJECTION

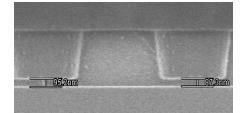


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Forecast Sales Revenue Exposure €M - most likely scenario

